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Class	Subclass

ISSUE CLASSIFICATION

PATENT NUMBER

U.S. UTILITY Patent Application

JL2
JC858

O.I.P.E.

PATENT DATE

122
SCANNED

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11.

APPLICATION NO.
09/662682

CONT/PRIOR

CLASS
438

SUBCLASS

ART UNIT
1765

EXAMINER

Vinh

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Metal-assisted chemical etch porous silicon formation method

PTO-2040
12/99

ISSUING CLASSIFICATION

ORIGINAL				CROSS REFERENCE(S)							
CLASS		SUBCLASS		CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)						
INTERNATIONAL CLASSIFICATION											

<input type="checkbox"/> TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg. _____	Figs. Drwg. _____	Print Fig. _____	Total Claims _____	Print Claim for O.G. _____
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<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S. Patent No. _____	_____ (Primary Examiner) _____ (Date)			ISSUE FEE	
				Amount Due _____	Date Paid _____
<input type="checkbox"/> The terminal _____ months of this patent have been disclaimed.	_____ (Legal Instruments Examiner) _____ (Date)			ISSUE BATCH NUMBER	
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